	Application No.	Applicant(s)
Notice of Allowability	10/849,263	KIMURA, KOICHI
	Examiner	Art Unit
	Tuyen Q. Tra	2873
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>06/12/2006</u> .		
2. The allowed claim(s) is/are <u>1-15</u> .		
 3.		
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Summary Paper No./Mail Dat 8), 7. ☐ Examiner's Amendn	e

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DETAILED ACTION

Reason For Allowance

1. Claims 1-15 are allowed.

2. Following is an examiner's statement of reasons for allowance:

The prior art taken either singularly or in combination fails to anticipate or fairly suggest the limitations of the independent claim(s), in such a manner that a rejection under 35 U.S.C. 102 or 103 would be proper. The prior art fails to teach a combination of all the claimed features as presented in independent claims 1, 3, 5 and 7, which include (claim 1) a transmissive light modulation section including a microelectromechanical element being controlled by the pixel drive circuit and being provided above the pixel drive circuit, (claim 3) step for attaching a transparent substrate to a location from which the first silicon layer was remove, forming a transparent light modulation section including a micro electromechanical element above the pixel drive circuit; (claim 5) step for forming a transmissive light modulation section including a micro-electromechanical element in the area from which the first silicon layer was removed; (claim 7) step for forming a transmissive light modulation section including a micro-electromechanical element above the pixel drive circuit.

3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

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4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

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- a) Gomi (US Patent 6,970,212 B1) disclose electro-optical device and method for fabricating the same comprising of an opposite substrate (20) includes a lens array substrate (LA) in which a plurality of convex microlenses (small condenser lenses), pixel electrodes (8), a liquid crystal apparatus substrate (30), and a transparent glass sheet 49 adhered to the lens array substrate LA by an adhesive (48) so as to cover the microlenses (L); however, Gomi does not teach or fairly suggest a transmissive light modulation section including a micro-electromechanical element being controlled by the pixel drive circuit and being provided above the pixel drive circuit.
- b) Kubo et al. (US Patent 6,330,047B1) discloses display device in Figure 7 comprising of substrate (11), pixel circuit on insulation layer (7) and therefore on substrate layer (11), micro-electromechanical section (1) above pixel circuit; however, Kubo et al. does not teach or suggest does not teach or fairly suggest a micro-electromechanical element being controlled by the pixel drive circuit and being provided above the pixel drive circuit and/or method of forming a transmissive light modulation section including a micro-electromechanical element in the area from which the first silicon layer was removed.
- 5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuyen Q. Tra whose telephone number is 571-272-2343. The examiner can normally be reached on 9:30-6:00.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ricky L. Mack can be reached on 571-272-2333. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

TT

August 12, 2006